1. Buyer

1.1 Buyer

Official name:	Universiteit Twente
Legal type of the buyer:	Body governed by public law
Activity of the contracting authority:	Education

2. Procedure

2.1 Procedure

Title:	European Tender Direct Laser Writing system
Description:	The University of Twente is tendering to purchase a Direct Laser Writing system. The MESA+ Institute of the University of Twente will invest in a new Direct Laser Writing system (DLW-system) for maskless lithography, to extent the current capacity regarding this lithographic technique. A system suitable for defining patterns in various photoresists, at high resolution and high speed, compatible with a wide range of applications and substrate types up to 200 mm in diameter. The system will be used by a wide range of users, i.e. academic researchers and students as well as industrial engineers with different backgrounds and different levels of expertise. This DLW-system will be applied for defining patterns in photoresist films to fabricate functional structures and devices in the fields of photonics, micro/nano-fluidics, (nano) electronics, etc.
Procedure identifier:	d1d33627-8e92-4fe7-847f-35531a00e805
Previous notice:	8b36f03d-eb09-4090-96f8-ba1148edd02f-01
Internal identifier:	3df468f0-9c37-4ed2-a8fd-2cfff88f31c3
Type of procedure:	Open
The procedure is accelerated:	no

2.1.1 Purpose

Main nature of the contract :	Supplies
Main classification (cpv):	38000000 Laboratory, optical and precision equipments (excl. glasses)

2.1.2 Place of performance

Country:	Netherlands

Anywhere in the given country

Additional information:	Zie documentatie

2.1.3 Value

Estimated value excluding VAT:	600 000 Euro

2.1.4 General information

Legal basis:

Directive 2014/24/EU

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5. Lot

5.1 Lot technical ID: LOT-0000

Title:	European Tender Direct Laser Writing system
Description:	The University of Twente is tendering to purchase a Direct Laser Writing system. The MESA+ Institute of the University of Twente will invest in a new Direct Laser Writing system (DLW-system) for maskless lithography, to extent the current capacity regarding this lithographic technique. A system suitable for defining patterns in various photoresists, at high resolution and high speed, compatible with a wide range of applications and substrate types up to 200 mm in diameter. The system will be used by a wide range of users, i.e. academic researchers and students as well as industrial engineers with different backgrounds and different levels of expertise. This DLW-system will be applied for defining patterns in photoresist films to fabricate functional structures and devices in the fields of photonics, micro/nano-fluidics, (nano) electronics, etc.
Internal identifier:	d163a995-33b6-4144-b1cc-c6eceff32b17

5.1.1 Purpose

Main nature of the contract :	Supplies
Main classification (cpv):	38000000 Laboratory, optical and precision equipments (excl. glasses)

5.1.2 Place of performance

Country:	Netherlands

Anywhere in the given country

Additional information:	Zie documentatie

5.1.3 Estimated duration

Duration:	2 Year

5.1.5 Value

Estimated value excluding VAT:	600 000 Euro

5.1.6 General information

Procurement Project not financed with EU Funds.

The procurement is covered by the Government Procurement Agreement (GPA):	yes

5.1.10 Award criteria

Criterion:	
Type:	Quality
Description:	Wishes
Category of award threshold criterion:	Weight (points, exact)

Award

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criterion number:	45
Criterion:	
Type:	Quality
Description:	Sustainability
Category of award threshold criterion:	Weight (points, exact)
Award criterion number:	10
Criterion:	
Type:	Price
Description:	Price
Category of award threshold criterion:	Weight (points, exact)
Award criterion number:	45

5.1.15 Techniques

Framework agreement:

No framework agreement

Information about the dynamic purchasing system:

No dynamic purchase system

5.1.16 Further information, mediation and review

Review organisation:	Rechtbank Overijssel
Information about review deadlines:	See descriptive document

6. Results

Value of all contracts awarded in this notice:	500 000 Euro

6.1 Result lot Identifier: LOT-0000

At least one winner was chosen.

6.1.2 Information about winners

Winner:

Official name:	Raith GmbH

Tender:

Tender identifier:	EB OUT 7038
Identifier of lot or group of lots:	LOT-0000

Value of the

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tender:	500 000 Euro
Subcontracting :	No

Contract information:

Identifier of the contract:	EB OUT 7038
Date of the conclusion of the contract:	05/10/2026

6.1.4 Statistical information

Summary of the review requests the buyer received:

Number of complainants:	0

Received tenders or requests to participate:

Type of received submissions:	Tenders
Number of tenders or requests to participate received:	2

8. Organisations

8.1 ORG-0001

Official name:	Universiteit Twente
Registration number:	50130536
Postal address :	Drienerlolaan 5
Town:	Enschede
Postcode:	7522NB
Country subdivision (NUTS):	Twente (NL213)
Country:	Netherlands
Contact point:	Dionne Hooijmans
Email:	d.hooijmans@utwente.nl
Telephone:	+31534897908
Internet address:	https://www.utwente.nl
Buyer profile:	https://s2c.mercell.com/buyer/16033

Roles of this organisation:

Buyer

8.1 ORG-0002

Official name:	Rechtbank Overijssel
Registration number:	82940525
Town:	Almelo
Postcode:	7607 GB

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Country subdivision (NUTS):	Twente (NL213)
Country:	Netherlands
Email:	communicatie.rb-ove@rechtspraak.nl
Telephone:	(+31)0883611042

Roles of this organisation:

Review organisation

8.1 ORG-0003

Official name:	Raith GmbH
Size of the economic operator:	Medium
Registration number:	HRB8984
Postal address :	Konrad-Adenauer-Allee 8
Town:	Dortmund
Postcode:	44263
Country subdivision (NUTS):	Dortmund, Kreisfreie Stadt (DEA52)
Country:	Germany
Contact point:	Marc Ujma
Email:	marc.ujma@raith.com
Telephone:	004915120743536
Internet address:	https://raith.com/

Roles of this organisation:

Tenderer

Winner of these lots:	LOT-0000

Notice information

Notice identifier /version:	e4f08c56-4167-4544-b603-7b2b1f294317 - 01
Form type:	Result
Notice type:	Contract or concession award notice – standard regime
Notice dispatch date:	06/10/2026 09:21 +00:00
Notice dispatch date (eSender):	06/10/2026 09:21 +00:00
Languages in which this notice is officially available:	English

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